

# United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address - Comment of the Patentia Acts Trade Manufacture
Washington 1000 20211
Washington 1000 20211

"Marine Santa				CONFIRMATION NO
APPLICATION NO 10 002,696	HLING DATE 10 31 2001	FIRST NAMED INVENTOR Eliyahou Harari	ATTORNEY DOCKET NO 11587 M-12336 US	4652

7590

01/22/2003

27869 SKJERVEN MORRILL LLP THREE EMBARCADERO CENTER, 28TH FLOOR SAN FRANCISCO, CA 94111

EXAMINER WEISS, HOWARD

PAPER NUMBER ART UNIT 2814

DATE MAILED: 01/22/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)		
	10/002 696	HARARI ET AL		
Summary	Examiner	Art Unit		
Office Action Summary		2814		
	nears on the cover shee	t with the correspondence address		
The MAILING DATE of this communicate. Period for Reply	Y IS SET TO EXPIRE			
A CHORTENED STATUTORY PERIOD FO		·		
THE MAILING DATE OF THIS COMMUNIC.  Extensions of time may be available under the provisions.	36(a) In no event, he æver, ma	w to a send and timely		
after SIX (6) MONTHS from the fluctuation of the period for reply specified above its less than thirty (30). If the period for reply is specified above, the maximum states of the period for reply is specified above, the maximum states for reply within the set or extended period for reply and approximately set of the period for reply and the period period for reply specified above its maximum state.	y within the statutory reminum of thirty (30) days will be considered timely will apply and will expressive SIX (6) MONTHS from the mailing date of this communication will apply and will expressive SIX (6) MONTHS from the mailing date of this communication become ABANDONED (35 U.S.C. § 133).  It date of this communication leven if timely filed, may reduce any			
1) Responsive to communication(s) file	November 2002			
- CINIAL 21	ns action is non-final.			
=	ance except for forma	I matters, prosecution as to the merits is		
Since this application is in condition to closed in accordance with the practice	Ex parte Quayle, 193	5 C.D. 11, 453 O.G. 213.		
Disposition of Claims  4)  Claim(s) 13.15-23 and 25-36 is/are :	i the application			
4a) Of the above claim(s) is/ai(	an from consideratio	n.		
- idara allowed				
- 10 45 02 and 25-36 is/are re				
6)[:] Claim(s) 13,15-23 and 25-53 identified to				
7) Claim(s) is/are objected to.	r election requireme	nt.		
8) Claim(s) are subject to restrict				
Application Papers  9) The specification is objected to by the 5	٠ ۲.			
10) The drawing(s) filed on is/are	oren of the Tublestea	to by the Examiner.		
Applicant may not request that any objection	e drawing(s) be held i	n abeyance See 37 CFR 1 85(a)		
11) The proposed drawing correction filed	_is a) ☐ approved	is a) approved b) disapproved by the Examiner.		
If approved corrected drawings are red.	ply to this Office actio			
12) The oath or declaration is objected to	aminer.			
Priority under 35 U.S.C. §§ 119 and 120	. priority under 35 t	J.S.C. § 119(a)-(d) or (f).		
13) Acknowledgment is made of a claim to	,			
a) ☐ All b) ☐ Some * c) ☐ None of	s have been receiv	ved.		
1. Certified copies of the priority d	s have been receiv	ved in Application No		
2. Certified copies of the priority d	, and a loop	ve been received in this National Stage		
3.☐ Copies of the certified copies of application from the Internation from the Internation action. ★ See the attached detailed Office action	reau (PCT Rule 1	reau (PCT Rule 17.2(a)). of the certified copies not received.		
* See the attached detailed of a claim for	i : C priority under 35	5 U.S.C. § 119(e) (to a provisional application).		
14) Acknowledgment is made of a claim for	wisional application	on has been received.		
a) ☐ The translation of the foreign land 15)☐ Acknowledgment is made of a claim fo		5 U.S.C. §§ 120 and/or 121.		
Attachment(s)	41 Fi	Interview Summary (PTO-413) Paper No(s)		
<ol> <li>Notice of References Cited (PTO-89.)</li> <li>Notice of Draftsperson's Patent Drazing Review FT</li> <li>Minformation Disclosure Statements</li></ol>	. 5, 🗀	Notice of Informal Patent Application (P10-132) Other		
Figure 1 Trademain 17	ition Summary	Part of Paper No 13		

Attorney's Docket Number M-12336 US

Filing Date: 10/31/01

Continuing Data, none

Claimed Foreign Priority Date: none

Applicant(s): Hararı et al. (Samachisa Yuan, Guterman)

Examiner: Howard Weiss

#### Claim Objections

- Claim 28 is objected to under 37 CFR 1.75(c) as being in improper form because dependent claim cannot be dependent upon a multiple dependent claim. See MPEP § 608.01(n). Accordingly, the claim has not been further treated on the merits.
- 2. IN Claims 13 and 23. "injection or curce-side" should be changed to ---injection and source-side---. Appropriate correct on is required.

### Claim Rejections - 35 USC § 112

3. The following is a quotation of the recond paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

- 4. Claim 26 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.
- 5. Claim 26 recites the limitation "at east first and second gate elements" in Lines 1 and 2. There is insufficient antece tent basis for this limitation in the claim.

### Claim Rejections - 35 USC § 103

6 The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in his Office action:

(a) A patent may not be obtained thou. The invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be regatived by the manner in which the invention was made.

This application currently names and inventors. In considering patentability of the claims under 35 U.S.C. 103(a). th∈ ∈xaminer presumes that the subject matter of the various claims was commonly or ned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to : > nt out the inventor and invention dates of each claim that was not commonly owred at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e). (f) or (g) prior art under 35 U.S.C. 103(a).

7 Claims 13, 15, 17 and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Eitan (U.S. Patent No. 6,011 25) and Reisinger (U.S. Patent No. 6,137,718)

Eitan shows most aspects of the instant invention (e.g. Figures 2 to 12) including:

- rogramming means (Column 2 Line 60 to Column 13 Line 33) supplying voltages to the gates 24, source 14 and drain 16 regions to one of two threshold levels in one of two defined portions 23 of a charge storage dielectric 18 containing silicon nitride
- reading means for reading the programmed values as claimed (Column 13 Line 35 to Column 17 Line 30)

Eitan does not show the storage c' more then two defined ranges. Reisinger teaches (e.g. Figure 1) to store four (Colui in 7 Lines 25 to 30) or more (Column 6 Lines 5 to 35) ranges in a charge storage di ∈ctric 52 in order to increase the storage density (Column 2 Lines 7 to 12) It would have been obvious to a person of ordinary skill in the art at the time of invention to store four or more ranges in a charge storage dielectric as taught by Reisinger the device of Eitan in order to increase the storage density

In reference to the claim language referring to how the cells are programmed (either by channel hot-electron or source side injection), intended use and other types of functional language must result in a structural difference between the claimed invention and the prior art in ordinary to patentably distinguish the claimed invention from the prior art. If the prior art is capable of performing the intended use, then it meets the claim. In a claim drawn to a process of making, the intended use must result in a manipulative therence as compared to the prior art. In reaction of the memory cells in Eitan and Reisinger show the same structure (i.e. a three is ered dielectric storage layer) and, therefore, are capable of being used as claimed.

8. Claim 16 is rejected under 35 U  $_{\odot}$  C. 103(a) as being unpatentable over Eitan and Reisinger, as applied to Claim 13 above, and further in view of DiMaria (Journal de Physique 1981)

Eitan and Reisinger show most as: ects of the instant invention (Paragraph 7) except for the charge storage dielectric including silicon rich silicon dioxide. DiMaria teaches (e.g. Figure 3) to use a charge storage dielectric including silicon rich silicon dioxide to produce a memory device with excellent breakdown characteristics (Page C4-1117 second paragraph). It would have been obvious to a person of ordinary skill in the art at the time of invention to the act at the time of invention to the act at the time of invention to the act at the device of Eitan and Reisinger to produce a memory device with excellent breakdown characteristics.

9. Claims 19, 21 to 26, 29 to 31 and 33 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ma et al. (U.S. Fatent No. 5,278,439) and Reisinger.

Ma et al. show most aspects of the restant invention (e.g. Figures 2 and 3) including:

- an array of memory cells 20. 2 with elongated source and drain regions 20A. 22A within a substrate 26 and extending in a first direction and separated in a second direction perpendicular c said first direction
- a channel region 22 extending tween said source/drain regions
- refirst and second conductive sontrol) gates 20C, 22C extending in said first direction and first and second storage elements 20B, 22B
- conductive word lines 28 extending in said second direction
- a third control transistor gate 2 A positioned between said storage elements and channel 24G coupled by a gate dielectric to

Ma et al. shows do not show the storage of more then two defined ranges using charge storage dielectric. Reising teaches (e.g. Figure 1) to store four (Column 7 Lines 25 to 30) or more (Colun 6 Lines 5 to 35) ranges in a charge storage dielectric 52 in order to increase re storage density (Column 2 Lines 7 to 12). It would have been obvious to a serson of ordinary skill in the art at the time of invention to store four or more ranges in a charge storage dielectric as taught by Reisinger in the device of Ma et a proder to increase the storage density.

In reference to the claim language referring to how the cells are programmed (either by channel hot-electron or source side injection) and read, intended use and other types of functional language me t result in a structural difference between the claimed invention and the prior tiln order to patentably distinguish the claimed invention from the prior art. If the prior art structure is capable of performing the intended use, then it meets the country in a claim drawn to a process of making, the intended use must result in a mar mulative difference as compared to the prior art. In re Casey.152 USPQ 235 (CCP+ 1967): In re Otto , 136 USPQ 458, 459 (CCPA 1963).

10 Claims 20 and 22 are rejected up that 35 U.S.C. 103(a) as being unpatentable over Ma et al. and Reisinger, as applie to Claim 19 above, and further in view of Eckert et al. (U.S. Patent No. 5,889,303,

Ma et al and Reisinger show in except for the charge trapping in gates. Eckert et al. teach (e.g. Fi Lines 37 to 60) It would have bee the time of invention to have ch gates as taught by Eckert et al gate oxide stress.

· aspects of the instant invention (Paragraph 9) al extending continuously between two control res 10 and 11) to have charge storage material 106 extend between two control gives 110a,b to reduce gate oxide stress (Column 2 obvious to a person of ordinary skill in the art at storage material extend between two control me device of Ma et al. and Reisinger to reduce

under 35 U.S.C. 103(a) as being unpatentable 11. Claims 27, 32 and 33 are reject over Ma et al. and Reisinger as a collect to Claim 19 above, and further in view of Aritome et al. (IEDM 95).

Ma et al. and Reisinger show me et aspects of the instant invention (Paragraph 9) into the substrate. Aritome et al. teach (e.g. except for the word lines recess the substrate to realize a very low bit cost (see Figure 1) to recess word lines in: us to a person of ordinary skill in the art at the Abstract). It would have been obtime of invention to recess word he as into the substrate as taught by Aritome et al. in to realize a very low bit cost. the device of Ma et al and Reisir

12. Claims 34 and 36 are rejected us set 35 U.S.C. 103(a) as being unpatentable over Ma et al. (U.S. Patent No. 6,346.7. 5 and hereinafter Ma '725) and Reisinger.

stant invention (e.g. Figures 3) including: Ma 725 show most aspects of the

- an array of memory cells S1 regions within a substrate 40 second direction perpendicula
- a channel region 80 extending
- conductive control lines 70 ex said source/drain regions in a
- conductive word lines 710 st second direction over said co space neighboring source/dra
- charge storage material 60 pc

S6 with elongated source 120 and drain 30 extending in a first direction and separated in a said first direction

- ween said source/drain regions
- ding in said first direction and adjacent one of st portion of space between said regions
- ed apart in said first direction, extending in said a lines and positioned over a second portion of ∌gions
  - n between said word and control lines

Ma 725 shows do not show the dielectric charge storage materia Reisinger teaches (e.g. Figure 1 (Column 6 Lines 5 to 35) rang programming and reading means (Column 2 Lines 7 to 12). It would the art at the time of invention storage material using programn Reisinger in the device of Ma 721

orage of more then two defined ranges using d the explicit programming and reading circuits. store four (Column 7 Lines 25 to 30) or more n dielectric charge storage material 52 using claimed in order to increase the storage density gave been obvious to a person of ordinary skill in store four or more ranges in dielectric charge and reading means as claimed as taught by order to increase the storage density.

In reference to the claim language by channel hot electron or sourctypes of functional language in claimed invention and the prior invention from the prior art. If the intended use, then it meets the C intended use must result in a mare Casey.152 USPQ 235 (CC: 1963).

sferring to how the cells are programmed (either age injection) and read, intended use and other result in a structural difference between the on order to patentably distinguish the claimed prior art structure is capable of performing the In a claim drawn to a process of making, the liative difference as compared to the prior art. In 367); In re Otto , 136 USPQ 458, 459 (CCPA 13. Claim 35 is rejected under 35 t and Reisinger, as applied to Clau-

103(a) as being unpatentable over Ma 725 gabove, and further in view of Eckert et al.

Ma 725 and Reisinger show ma except for the charge trapping " gates Eckert et al teach (e.g. F 106 extend between two control Lines 37 to 60) It would have be the time of invention to have cr gates as taught by Eckert et al gate oxide stress

sapects of the instant invention (Paragraph 12) at extending continuously between two control --- 10 and 11) to have charge storage material 110a,b to reduce gate oxide stress (Column 2 bvious to a person of ordinary skill in the art at storage material extend between two control the device of Ma '725 and Reisinger to reduce

## Respense to Arguments

14. The Applicants' arguments filed not persuasive. In reference to h functional or use limitation one. limitation translates to a significe. the instant invention. As stated  $\boldsymbol{\kappa}$ performing the intended use, th-Prior Art meets this standard.

2/02 have been fully considered but they are e combination of references are programmed, e patentable weight in a device claim if the nuctural difference in the resultant device and rejection: "If the prior art structure is capable of : meets the claim." The stated combination of

15. The Applicants arguments with considered but are moot in view

ect to claims 20, 27, 28 and 32 have been · @ new ground(s) of rejection.

#### inclusion

the new ground(s) of rejection presented in this 16. Applicant's amendment necess: See MPEP ACTION IS MADE FINAL. Accordingly. 7. 2 the extension of time policy as set forth in 37 Office action. § 706.07(a). Applicant is remin: CFR 1 136(a)

A shortened statutory period for MONTHS from the mailing date.

TWO MONTHS of the mailing day mailed until after the end of the shortened statutory period will example expire later than SIX MONTHS for months and statutory action. In the expire later than SIX MONTHS for months and statutory period will expire later than SIX MONTHS for months and statutory period will expire later than SIX MONTHS for months and statutory period for mailed until after the end of the statutory period for mailed until after the end of the statutory period for mailed until after the end of the statutory period for mailed until after the end of the shortened statutory period will experience the end of the statutory period will experience the end of the statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the shortened statutory period will experience the end of the end of the shortened statutory period will experience the end of the end

If this final action is set to expire THREE action. In the event a first reply is filed within if this final action and the advisory action is not E-MONTH shortened statutory period, then the on the date the advisory action is mailed, and FR 1.136(a) will be calculated from the mailing event, however, will the statutory period for reply the date of this final action.

facsimile transmission. Papers so Fax Center located in Crystal Poconform with the notice published 1989). The Art Unit 2814 Fax Center is to be applications. The official TC28 (703) 872-9319 Fax numbers overifying receipt of their fax by the

ay be submitted directly to Art Unit 2814 by the best best by the faxed to Art Unit 2814 via the Art Unit 2814. The faxing of such papers must the Official Gazette. 1096 OG 30 (15 November of number is (703) 308-7722 or -7724. The Art ed only for papers related to Art Unit 2814. Before-Final, (703) 872-9318, and After-Final, provide the fax sender with an auto-reply fax 3PTO.

18. Any inquiry concerning this concerning thi

unication or earlier communications from the ard Weiss at (703) 308-4840 and between the n Standard Time) Monday through Friday or by

Any inquiry of a general nature directed to the Group 2800 Rec

nating to the status of this application should be nist at (703) 308-0956.

19. The following list is the Examine

eld of search for the present Office Action:

Fie	ld of Scarch	D	ate
U.S Class / Subclass(es)	257/ 3. 6	thru 1/12	1/03
Other Documentation no Electronic Database(s): E		thru 1/1-	4/03
Electronic Battas ( )			

(

HW/hw 15 January 2003 Howard Weiss Examiner Art Unit 2814

Ξ,